One-Photon Ionization of Liquid Water upon 193 nm Laser Irradiation

Akyhiro IWATA,* Nobuaki NAKASHIMA,† Yasukazu IZAWA,† and Chiyoe YAMANAKA††

Research and Development Division, Kansai Electric Power Co., Nakanoshima 3-3-22, Kita-ku, Osaka 530-70

†Institute of Laser Engineering, Osaka University, Yamada-oka 2-6, Suita, Osaka 565

††Institute for Laser Technology, Utsubo-honmachi 1-8-4, Nishi-ku, Osaka 550

Water was photoionized through a one-photon process upon 193 nm laser irradiation. The quantum yield of photoionization was a few percent. Multiphoton ionization was not observed in this work, up to the laser fluence of $1.6\,\mathrm{J/cm^2}$.

The photolysis of water has been investigated by several workers.¹⁻⁵⁾ It is well known that water is photoionized by VUV irradiation and that the photoionization threshold is 6.5 eV.^{1,2)}

$$H_2O \xrightarrow{hv} H_2O^+ + e_{aq}^-$$

For 184.9 nm irradiation, the quantum yields of photoionization are $\leq 0.045^{1)}$ and $0.004.^{2)}$ On the other hand, water is photoionized by 266 nm laser irradiation through a two-photon process with a quantum yield of $0.15.^{3,4)}$ We have observed a one-photon ionization of water on 193 nm (6.4 eV) laser irradiation.

Water was produced by a superpure system (Super-Q, Milipore). The resistivity of water was $18 \text{ M}\Omega$ at $25 \,^{\circ}\text{C}$. Sample water in a fused silica cell was degassed by several freeze-pump-thaw cycles. The absorbance at $193 \,^{\circ}\text{C}$ nm was $0.04 \, \text{cm}^{-1}$ at $25 \,^{\circ}\text{C}$, and this value is in agreement with the previous value of triply distilled water, within experimental error. An excimer laser (EMG201MSC, Lambda Physik) with pulse width (FWHM) of $30 \,^{\circ}\text{N}$ ns was used as the excitation laser. Absorption of hydrated electrons formed by photoionization was monitored using a He-Ne laser ($632.8 \,^{\circ}\text{nm}$).

No absorption other than hydrated electrons was observed in the visible region on UV irradiation.²⁾ Figure 1 shows the dependence of the absorbance at 632.8 nm on the 193 nm laser fluence. The slope of 1 was obtained

using 1 and 10 cm cells. If ionization occurs through a one-photon process, the straight line of the relationship between the laser fluence and the absorbance on a linear scale should pass through the origin.⁷⁾ It is confirmed that this consideration can be applied to our data. The results indicate that the photoionization occurs through a one-photon process and that the photoionization threshold is lower than 6.4 eV. One-photon ionization was observed in the region of 0.11-1.6 J /cm². The quantum yield of photoionization was a few percent. The laser power dependence for 248 nm laser irradiation is shown in Fig. 2. The slope of 2 was obtained in the region of low laser fluence, and this shows that two-photon ionization took place. Nikogosyan and co-workers also observed two-photon ionization for 266 nm laser irradiation.^{3,4)} Our result is consistent with these previous ones.

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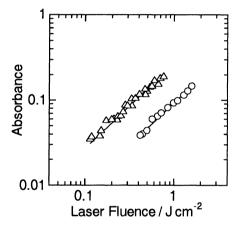


Fig. 1. Dependence of absorbance of hydrated electrons with optical length of 1 cm (\bigcirc) and 10 cm (\triangle) on laser fluence at 193 nm.

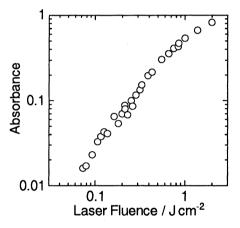


Fig. 2. Dependence of absorbance of hydrated electrons with optical length of 1 cm on laser fluence at 248 nm.

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